II. CLAIMS

1. (Currently Amended) An amine free [[A]] composition comprising ~~(essentially consisting of)~~ a combination of one or more essentially nonvolatile, unsaturated esters, ethers or ether-esters ~~esters/ethers/ether-esters~~, and a low glass transition temperature (Tg) latex resin.

2. (Canceled)

3. (Previously Presented) The composition of claim 1, further comprising a organornetallic.

4, (Original) The composition of claim 1, wherein the composition is a latex coating, ink or paint.

5. (Currently Amended) An amine free latex resin coalscent composition which ~~The composition of claim 1, wherein the coalescent~~ comprises ~~(consists essentially of)~~ the combination of one or more essentially nonvolatile, unsaturated esters, ethers or ether-esters ~~esters/ethers/ether-esters~~, and a low glass transition temperature (Tg) latex resin.

6. (Canceled)

7. (Currently Amended) The composition of claim 5, wherein the coalescent further comprises ~~(consists essentially of~~ an organometallic.

8. (Canceled)

9. (Currently Amended) The composition of claim 1, wherein the composition is ~~essentially~~ devoid of ~~conventional~~ surfactants having vapor pressures of 0.1 mm Hg or more at 25 ^{0}C.

10. (Currently Amended) An amine free [[A]] coalescent system for latex resins comprising a combination of one or more essentially nonvolatile, unsaturated esters, ethers or ether-esters ~~esters/ethers/ether-esters~~, and low Tg latex resins.

11. (Currently Amended) The composition of claim 1, wherein the unsaturated esters, ethers or ether-esters ~~esters/ethers/ether-esters~~ comprise one or more hydroxyl functional groups.

12. (Currently Amended) An amine free [[A]] coalescent system for acrylic latex resins comprising a combination of one or more essentially nonvolatile, unsaturated esters, ethers or ether-esters ~~esters/ethers/ether-esters~~, and low Tg latex resin(s), and optionally from 0.2 to about 2 weight % of one or more organometallic based surfactants~~, and optionally from 0.1 to about 4% of essentially non-volatile reactive amine(s)~~.

13. (Currently Amended) An amine free [[A]] coalescent system for vinyl, and or vinyl copolymer latex resins comprising a combination of from 1 to 15% of one or more essentially nonvolatile, unsaturated esters, ethers or ether-esters ~~esters/ethers/ether-esters~~, and from 1 to 15% of low Tg latex resin(s), and optionally from 0.1 to about 2 weight % of one or more metallic based surfactants~~, and optionally from 0.1 to about 4% of essentially non-volatile reactive amine(s)~~.

14.(Currently Amended) An amine free [[A]] coalescent system for styrenic copolymer latex resins comprising a combination of one or more essentially nonvolatile, unsaturated esters, ethers or ether-esters ~~esters/ethers/ether-esters~~, and low Tg latex resin(s), and optionally from 0.1 to about 2 weight % of one or more metallic based surfactants~~, and optionally from 0.1 to about 4% of essentially non-volatile reactive amine(s)~~.

15. (Currently Amended) An amine free [[A]] coalescent system for polyurethane latex resins comprising a combination of one or more essentially nonvolatile, unsaturated esters, ethers or ether-esters ~~esters/ethers/ether-esters~~, and low Tg latex resin(s), and optionally from 0.1 to about 2 weight % of one or more metallic based surfactants~~, and optionally from 0.1 to about 4% of essentially non-volatile reactive amine(s)~~.

16. (Currently Amended) An amine free [[A]] coalescent system for polyester latex resins comprising a combination of one or more essentially nonvolatile, unsaturated esters, ethers or ether-esters ~~esters/ethers/ether-esters~~, and low Tg latex resin(s), and optionally from 0.1 to about 2 weight % of one or more metallic based surfactants~~, and optionally from 0.1 to about 4% of essentially non-volatile reactive amine(s)~~.

17. (Currently Amended) A method for coalescing a latex resin in the absence of an amine comprising combining a latex resin with one or more ~~an~~ essentially nonvolatile unsaturated esters, ethers or ether-esters ~~esters/ethers/ether-esters~~ and a low Tg latex resin.

18. (Original) The method of claim 17, further comprising combining from 0.2 to about 2 weight % of one or more

organometallic based surfactants.

19-30. (Canceled)